NEORMATION DISCLOSURE CITATION					Docket Number (Optional)		Application Number 09/198,376			
					Applicant(s) A. Okamoto					
~~ <del></del>					Filing Date		Group Art Unit			
:				09/198,376			3743			
Le revie	يجم بد	3)		U.S. PATE	ENT DOCUMENTS					
EXAMINER INITIAL	REP	DOCUMENT NUMBER	DATE	NAME		CLASS	SUBCLASS	FILING IF APPRO		
AF	1	5,330,708	7-19-94	Martinson et al.				4-26-93		
-										
•										
	<u> </u>	_								
<del></del>			-							
									_	
					<del></del>	<del></del>				
<u></u>							1			
	<b></b>			FOREIG	N PATENT DOCUMENTS		<b>I</b>			
	REF	DOCUMENT NUMBER DATE			COUNTRY CLASS		SUBCLASS	Translation		
			_	<del>                                     </del>			_	YES	NO	
	<u> </u>			ļ				ļ		
l				<u> </u>						
	-			OTHER	DOCUMENTS (Including	g Author, Title,	Date, Pertinent P	ages, Etc.)		
European Office Action dated 8-18-03										
AF		1						·		
AF		Article titled "Under Authors: Hendrix, C	Article titled "Understanding doped V/sub 2/0/sub 3/ as a functional positive temperature coefficient material" Authors: Hendrix, Chen, Wang and Cui dated 6-92							
EXAMINER /Allen Flanigan/					DATE CONSIDERED 06/29/2006					
EXAMINI not consid	ER: Ini lered. I	tial if citation considered, wheth nclude copy of this form with no	ner or not citation is i ext communication to	n conformar applicant.	nce with MPEP Section 609;	Draw line thr	ough citation if no	ot in conform	nance and	

Form PTO-A820 (also form PTO-1449) P09A/REV04

Patent and Trademark Office \* U.S. DEPARTMENT OF COMMERCE